



8th International Workshop on Mechanisms of Vacuum Arcs
(MeVArc 2019)

Study on the post-arc sheath and the post-arc current in vacuum interrupters

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Modeling and Simulations

2019

MeVArc 2019



Padova

Contents



Background



Simulations of post-arc sheath



Simulations of post-arc current



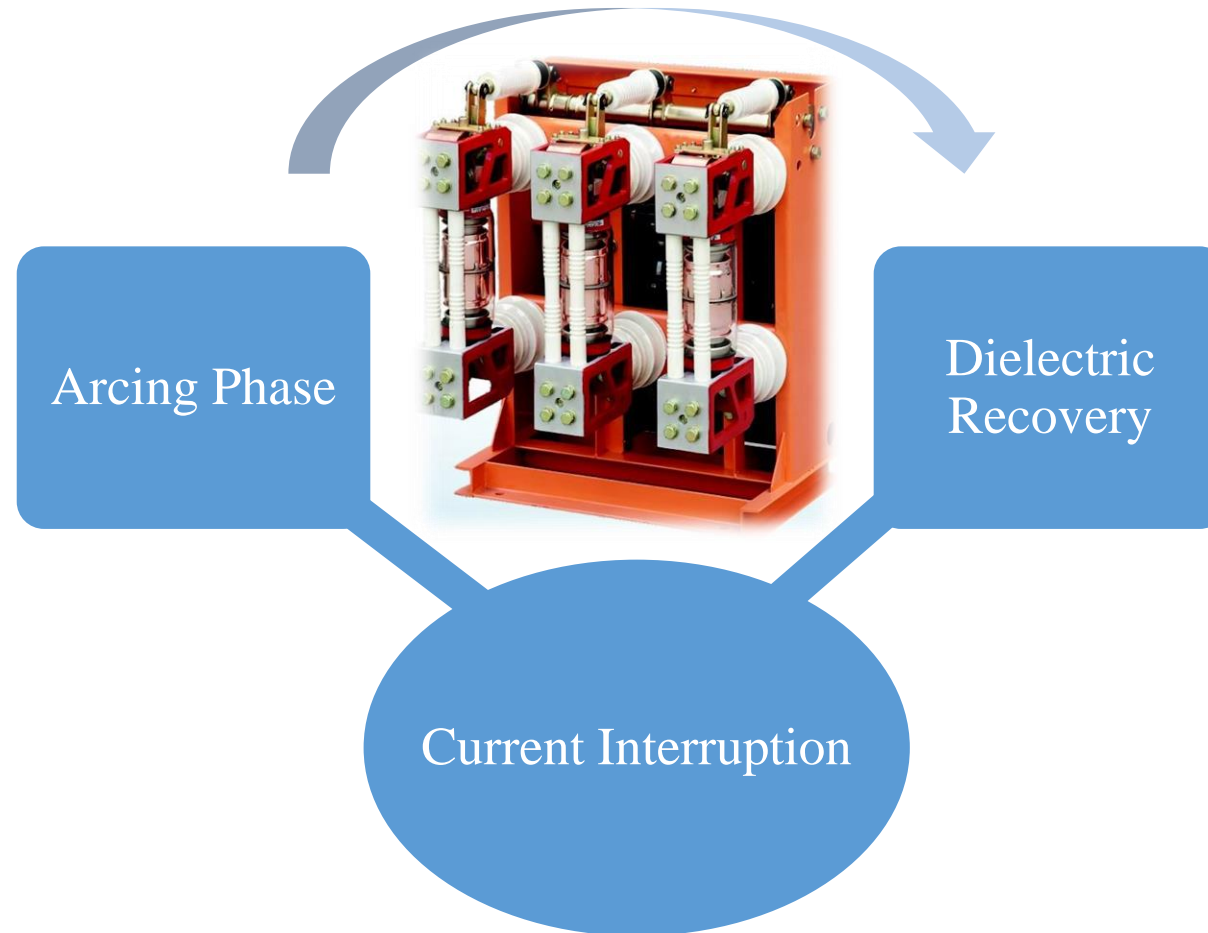
Experimental studies of post-arc current



Summary



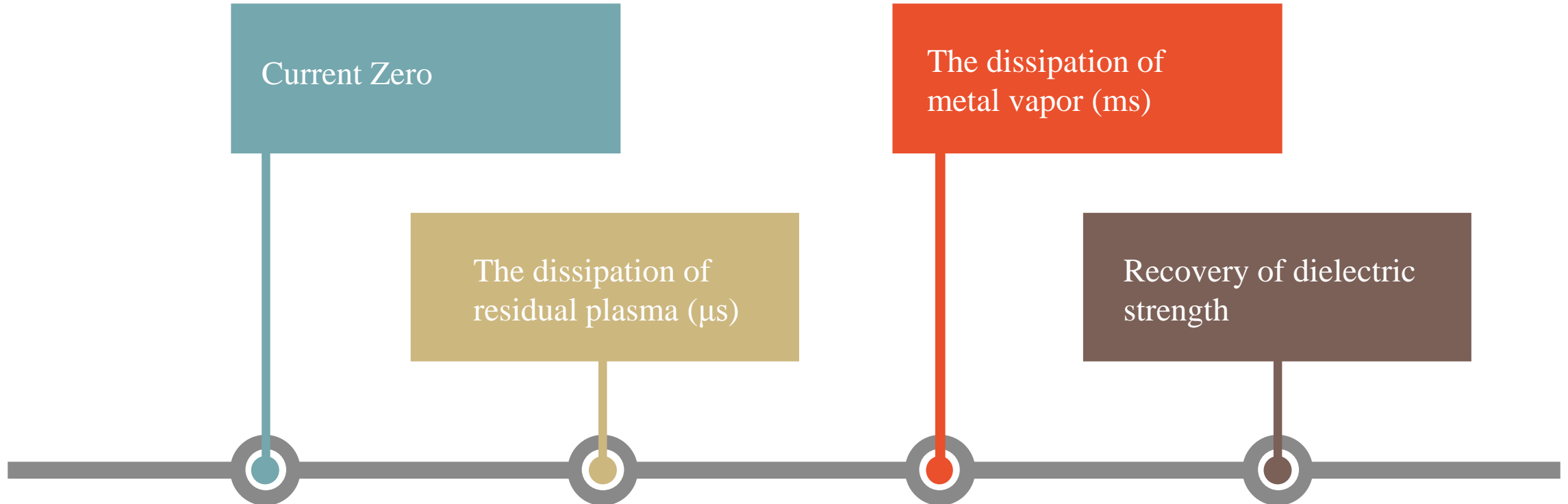
01. Background



The dielectric recovery process is important for a successful interruption.



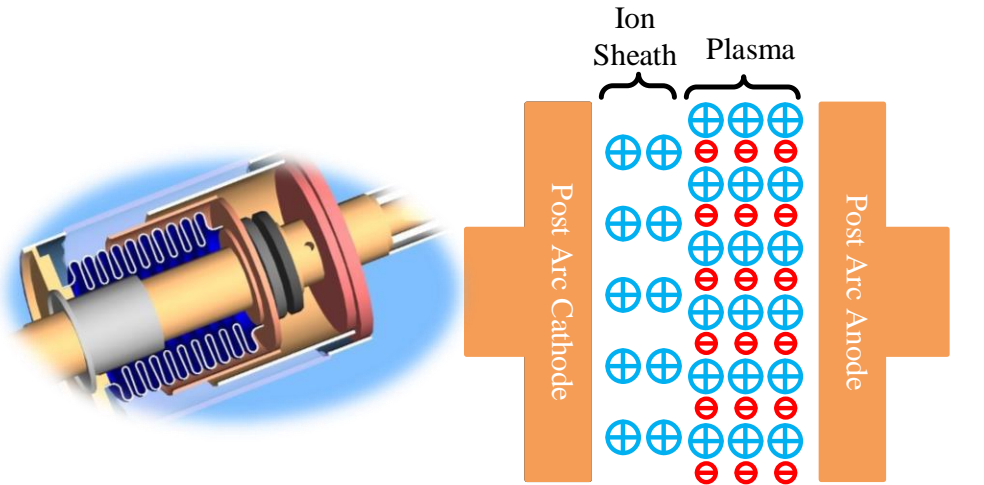
01. Background



The dissipation of residual plasma starts immediately after current zero, which is important for the study of dielectric recovery process.

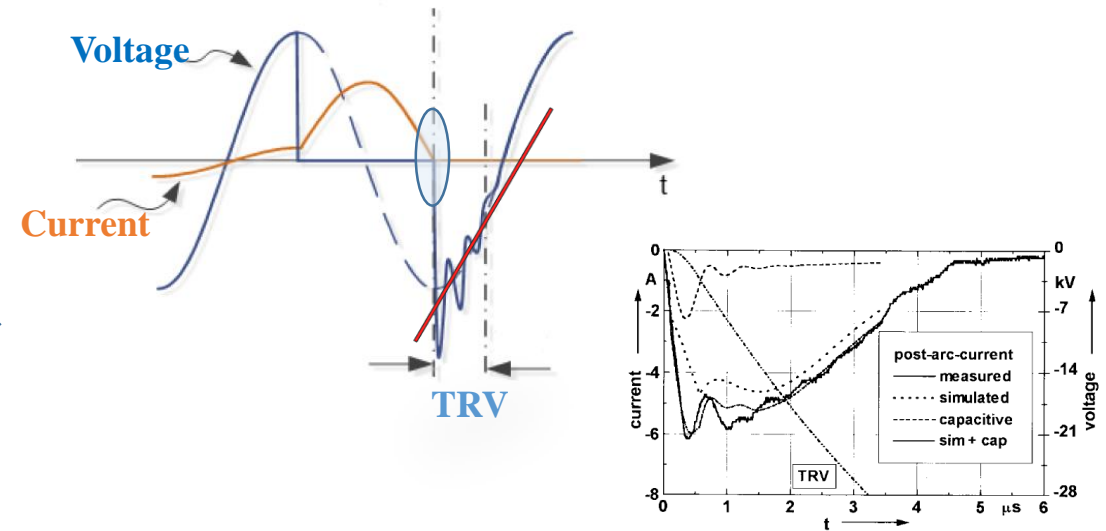


01. Background



The dissipation of residual plasma

Post-arc current



The post-arc sheath forms under the effect of transient recovery voltage. Meanwhile, the post-arc current forms when the charged particles are absorbed by the electrodes.



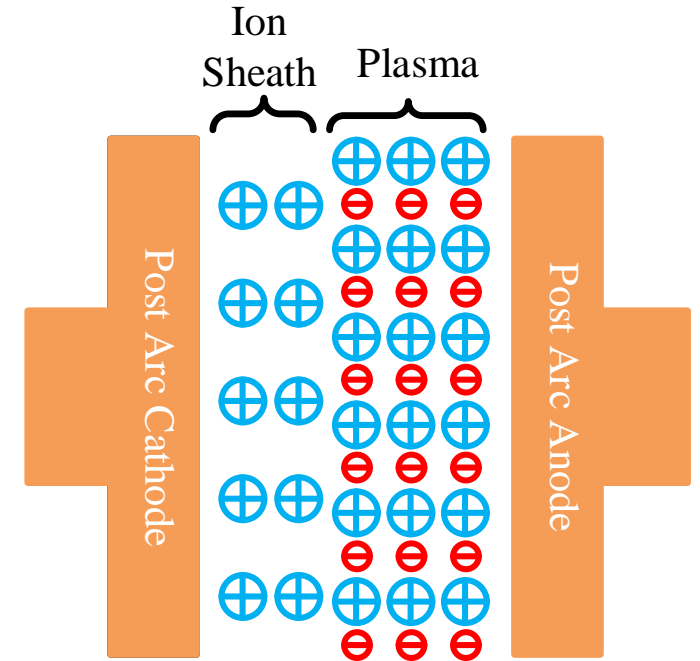
01. Background

■ Researches on post-arc current

■ Modeling & Simulations

➤ Continuous transition model (CTM)

- The derivation of this model is based on a semi-infinite collisionless plasma.
- It is numerically instable and not so self-consistent
- It requires little computational time
- The simulations with CTM agree well with the post-arc current obtain with experiments in relatively low current interruptions



1. J. G. Andrews and R. H. Varey, "Sheath Growth in a Low Pressure Plasma," *Physics of Fluids*, vol. 14, no. 2, pp. 339-343, 1971.
2. R. Holmes and S. Yanabu, "Post-arc current mechanism in vacuum interrupters," *Journal of Physics D: Applied Physics*, vol. 6, no. 10, p. 1217, 1973.
3. J. Kaumanns, "Measurements and modeling in the current zero region of vacuum circuit breakers for high current interruption," *IEEE Transactions on Plasma Science*, vol. 25, no. 4, pp. 632-636, 1997.



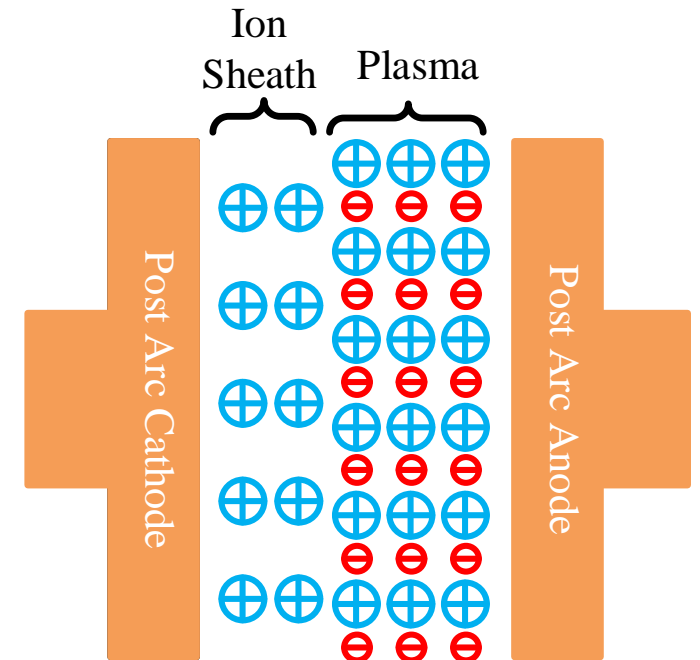
01. Background

■ Researches on post-arc current

■ Modeling & Simulations

➤ Hybrid Maxwell-Boltzmann model (Hybrid-MB model)

- The electron density is obtained from Maxwell-Boltzmann relation
- The ions are treated as particles
- It requires less computational time
- The influences of plasma density, the rising rate of transient recovery voltage, metal vapor, evaporation of electrodes, polarity effect on the post-arc sheath



1. P. Sarrailh, L. Garrigues, G. J. M. Hagelaar, J. P. Boeuf, G. Sandolache, and S. Rowe, "Sheath expansion and plasma dynamics in the presence of electrode evaporation: Application to a vacuum circuit breaker," *Journal of Applied Physics*, vol. 106, no. 5, pp. 053305-053305-12, 2009.
2. P. Sarrailh *et al.*, "Expanding sheath in a bounded plasma in the context of the post-arc phase of a vacuum arc," *Journal of Physics D: Applied Physics*, vol. 41, no. 1, p. 015203, 2008.
3. P. Sarrailh *et al.*, "Two-Dimensional Simulation of the Post-Arc Phase of a Vacuum Circuit Breaker," *IEEE Transactions on Plasma Science*, vol. 36, no. 4, pp. 1046-1047, 2008.



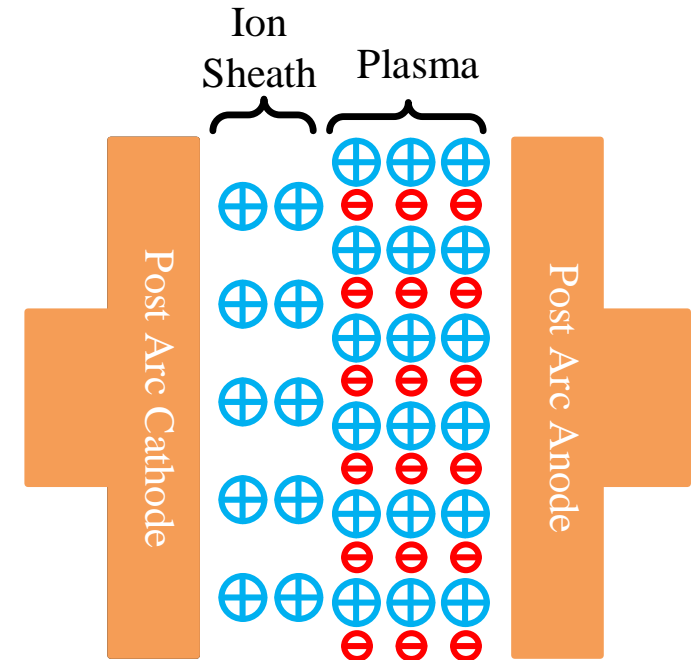
01. Background

■ Researches on post-arc current

■ Modeling & Simulations

➤ PIC model

- Both the electrons and ions are treated as particles
- It is more self-consistent and costs more computational time than the hybrid Maxwell-Boltzmann model
- The PIC model has been applied to the study of post-arc sheath in recent years. The influence of metal vapor on post-arc sheath and post-arc breakdown has been studied.



1. S. Jia, Y. Mo, Z. Shi, J. Li, and L. Wang, "Post-arc current simulation based on measurement in vacuum circuit breaker with a one-dimensional particle-in-cell model," *Physics of Plasmas*, vol. 24, no. 10, p. 103511, 2017.
2. Y. P. Mo, Z. Q. Shi, Z. B. Bai, S. L. Jia, and L. J. Wang, "Influence of residual plasma drift velocity on the post-arc sheath expansion of vacuum circuit breakers," *Physics of Plasmas*, vol. 23, no. 5, p. 053506, 2016.
3. Y. P. Mo, Z. Q. Shi, S. L. Jia, and L. J. Wang, "One-dimensional particle-in-cell simulation on the influence of electron and ion temperature on the sheath expansion process in the post-arc stage of vacuum circuit breaker," *Physics of Plasmas*, vol. 22, no. 2, p. 023511, 2015.
4. Y. Mo, Z. Shi, S. Jia, and J. Li, "Experimental Investigation on the Postarc Current in Vacuum Circuit Breakers and the Influence of Arcing Memory Effect," *IEEE Transactions on Plasma Science*, pp. 1-8, 2019.



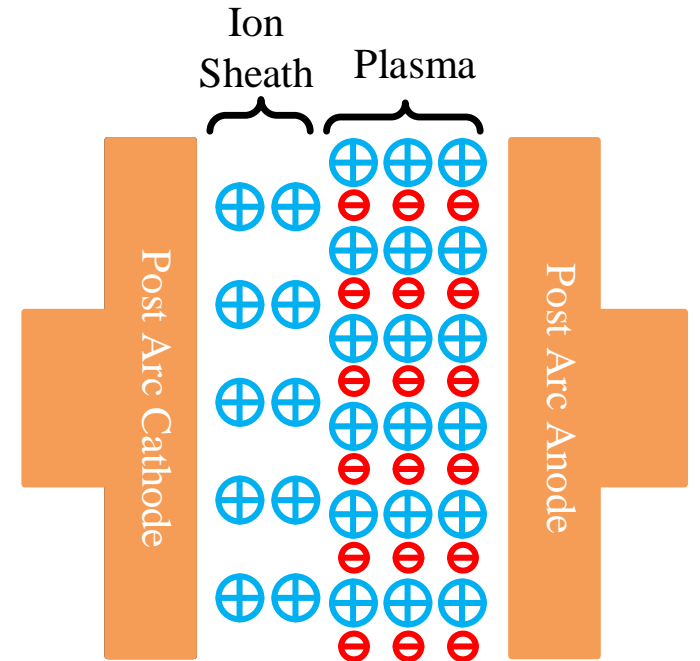
01. Background



Further study about post-arc current

Some questions

- How do the vacuum arc influence the formation of post-arc current still remains controversial in vacuum circuit breakers?
- How do the residual plasma influence the post-arc sheath expansion process are not very clear in vacuum circuit breakers ?



Contents



Background



Simulations of post-arc sheath



Simulations of post-arc current



Experimental studies of post-arc current



Summary



02. Simulations of post-arc sheath

1-D PIC model (both ions and electrons are treated as macro particles)

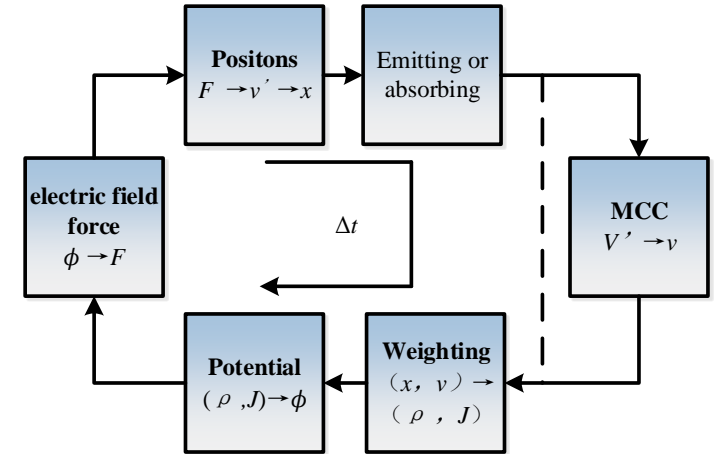
The potential and positions

$$\nabla^2 \phi = -e \left(\frac{n_i - n_e}{\epsilon_0} \right)$$

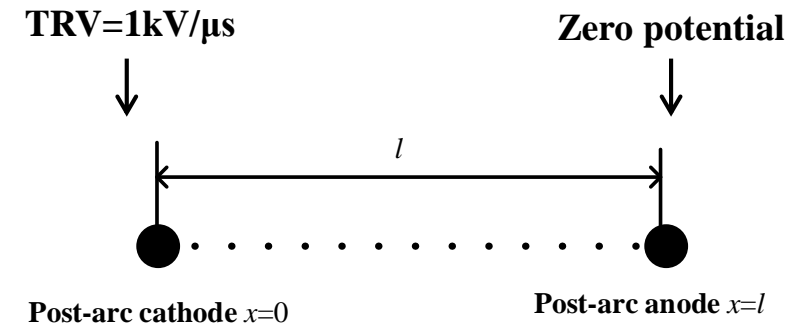
$$\frac{d^2 x}{dt^2} = \frac{qE}{m}$$

Constraint condition

- $\Delta x < \lambda_D$ λ_D is the Debye length
- $\Delta t < 2 / \omega_p$ ω_p is the plasma frequency
- $\Delta t < \frac{\Delta x}{v_e}$ v_e is the thermal velocity



Simulating program flowchart



Schematic diagram of simulation model



02. Simulations of post-arc sheath

■ Comparison of 1-D PIC model and CTM

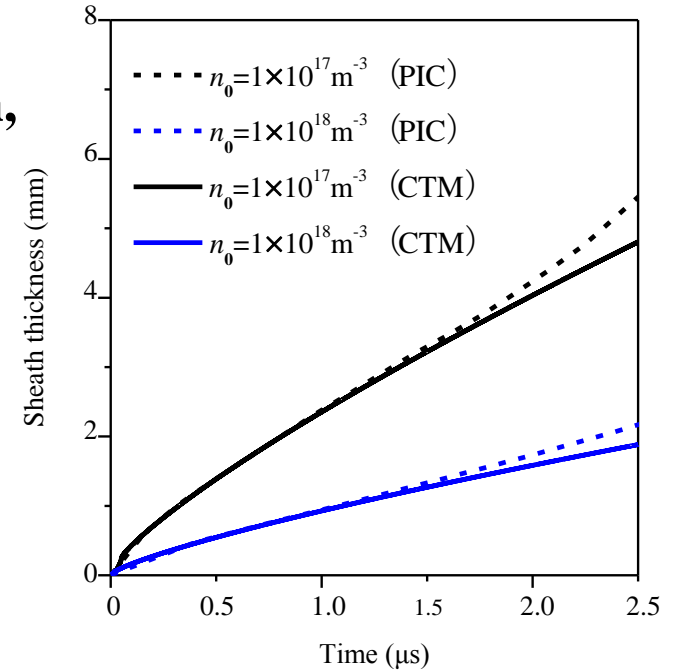
- Introduction of CTM (Deduced from Poisson Equation, Continuity Equation and Momentum Equation)

$$s^2 = \left[\frac{4\epsilon_0 V_0}{9en_0} \right] \left[\left(1 + \frac{V(t)}{V_0} \right)^{3/2} + \frac{3V(t)}{V_0} - 1 \right]$$

$$eV_0 = \frac{1}{2} M \left(u_0 - \frac{ds(t)}{dt} \right)^2$$

■ Results

- The sheath expansion process with CTM and PIC are similar in the initial stage
- The sheath with PIC expands faster than that with CTM after about 2 μs which is more close to actual value.



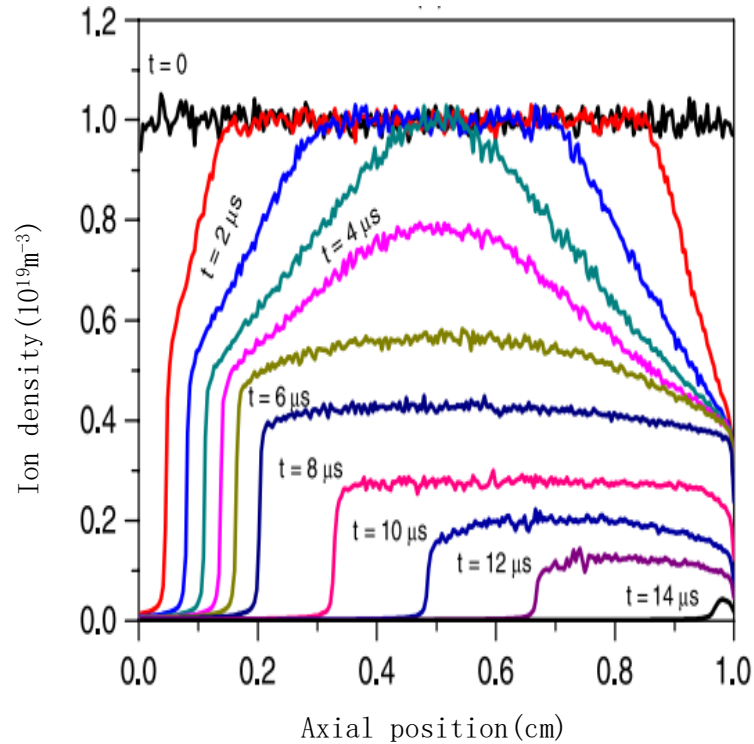
Comparison with CTM and PIC



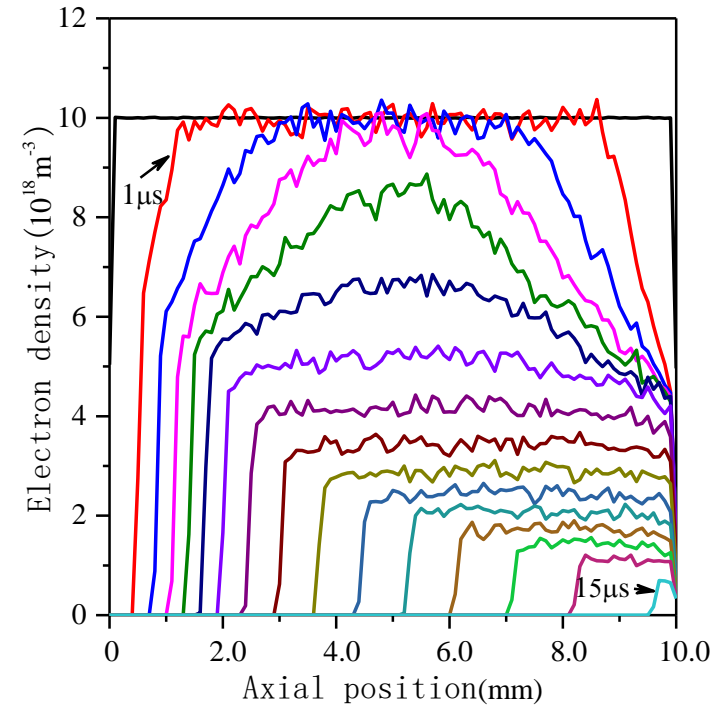
02. Simulations of post-arc sheath

■ Comparison of PIC model and Hybrid-MB model

■ The results with two models are close



Results with hybrid-MB model in Ref



Results with PIC model

Parameters : $n_0=1 \times 10^{19} \text{ m}^{-3}$, $T_e=1 \text{ eV}$, $T_i=1800 \text{ K}$, $\text{TRV}=1 \text{ kV}/\mu\text{s}$

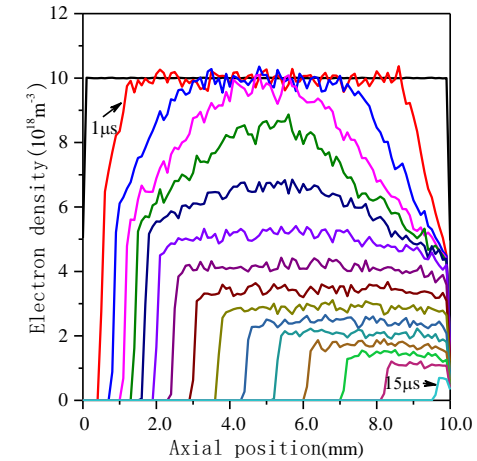


02. Simulations of post-arc sheath

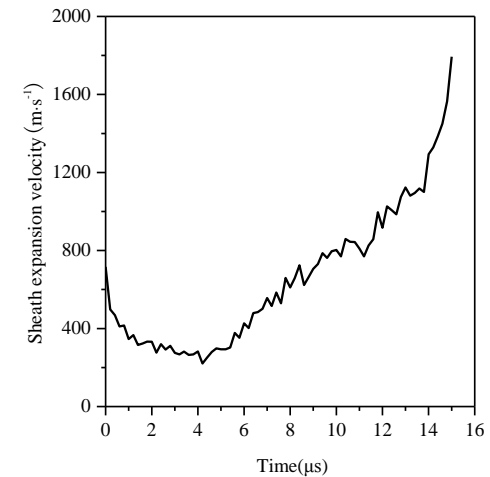


■ Introduction of ion rarefaction wave

- The ion rarefaction wave seems can be to explain the variation of plasma in the contact gap
 - When the sheath are stable, the plasma density of sheath edge are 0.4 times of the plasma density of wave front
 - Two ion rarefaction waves forms in both two electrodes and develop to the middle of the gap
 - When the two rarefaction waves meets in the middle of gap, the overall plasma density begins to decrease and the sheath expansion velocity begins to increase



Electron density taken from PIC model



Sheath expansion velocity taken from PIC model

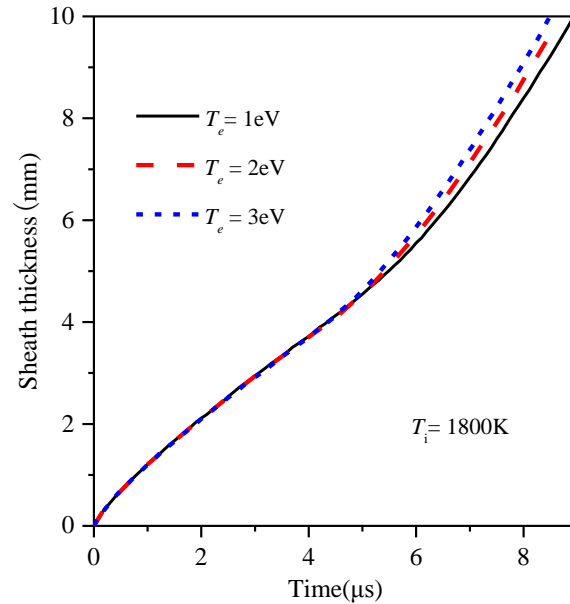


02. Simulations of post-arc sheath

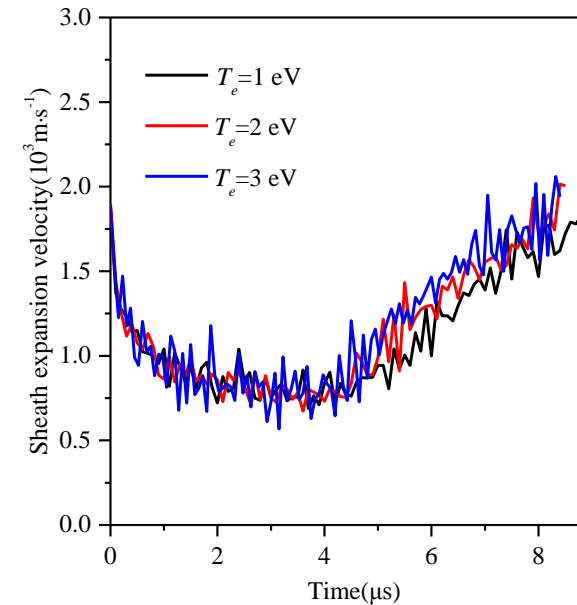
■ The post-arc sheath with different plasma temperatures

■ Influences of electron temperature

- The post-arc sheath expands faster to post-arc anode with higher electron temperature
- The sheath expansion process are similar in the initial stage with different electron temperature
- The sheath expansion velocity increases earlier with higher plasma temperature



The variation of sheath thickness

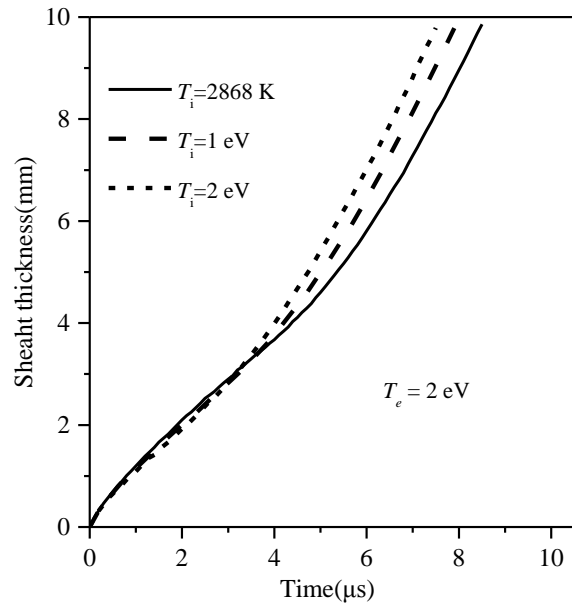


The variation of sheath expansion velocity

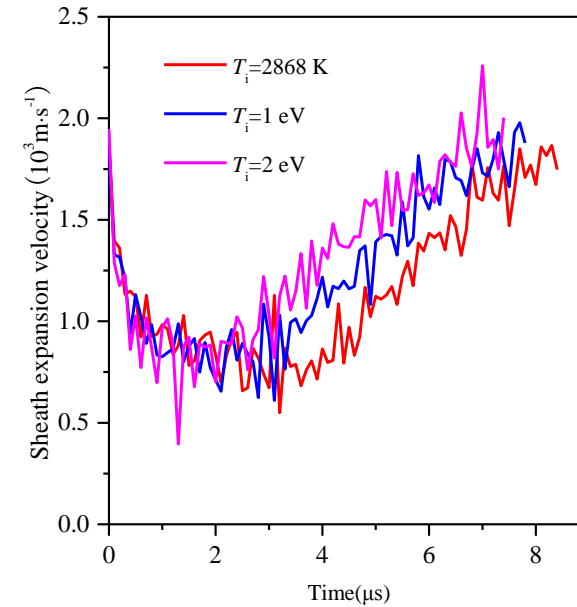


02. Simulations of post-arc sheath

- The post-arc sheath with different plasma temperatures
 - The influence of ion temperature
 - The post-arc sheath expands faster with higher ion temperature



The variation of sheath thickness

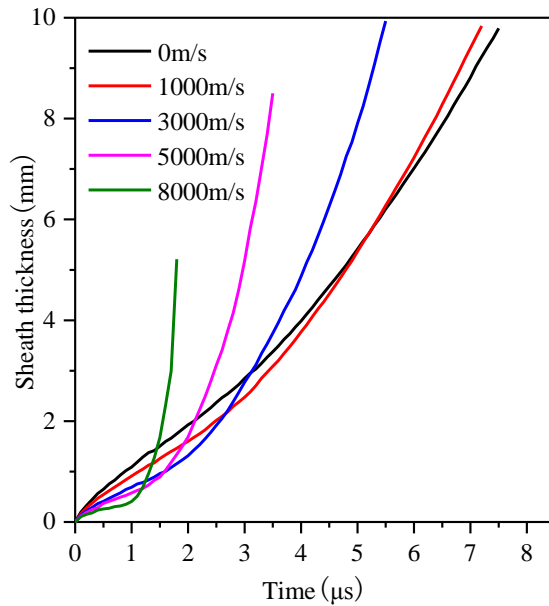


The variation of sheath expansion velocity

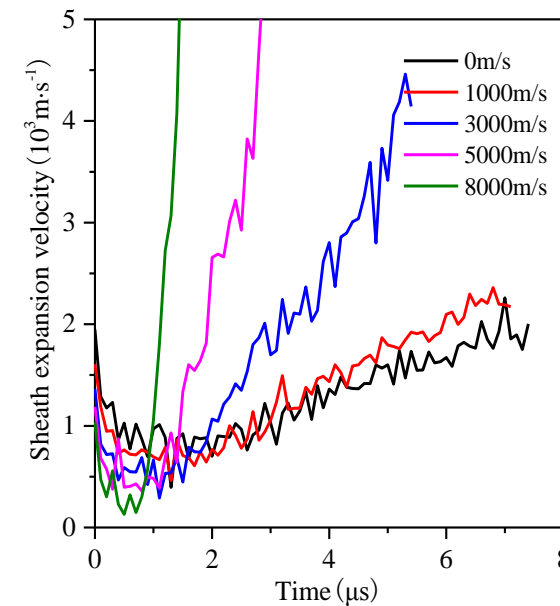


02. Simulations of post-arc sheath

- **The post-arc sheath with different initial plasma drift velocities**
 - **The influence of initial plasma drift velocity**
 - **The sheath expands faster with higher v_{drift}**
 - **The sheath expands slower with higher v_{drift} in the initial stage.**



The variation of sheath thickness



The variation of sheath expansion velocity



02. Simulations of post-arc sheath



■ The influence of metal vapor-estimation of metal vapor

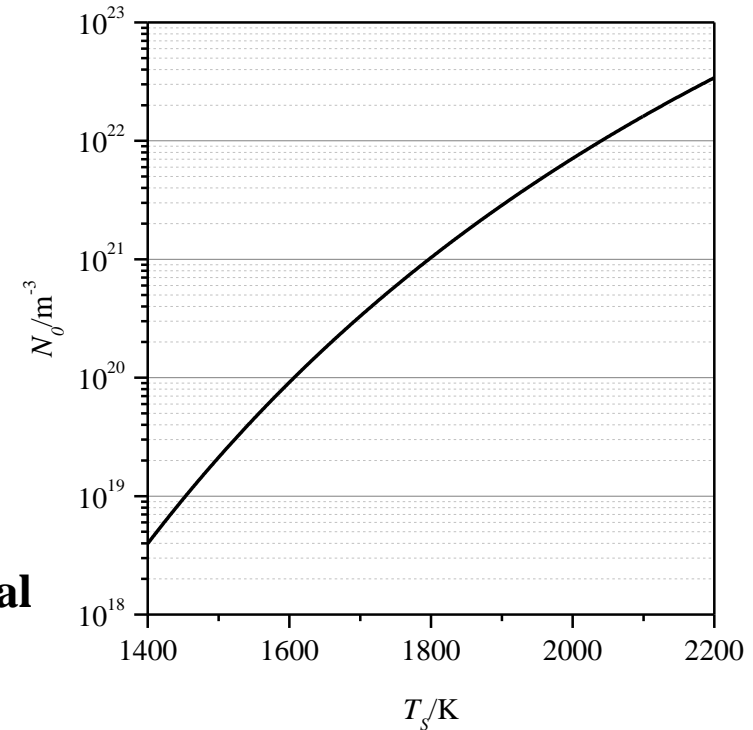
$$N_0 = N_s / 2$$

$$N_s = P_s / (k_B T_s)$$

$$P_s = P_{atm} \exp \left[-\frac{L}{R} \left(\frac{1}{T_s} - \frac{1}{T_{boil}} \right) \right]$$

T_s is the contact temperature

- The temperature of contact can achieve 2200 K, the metal vapor density also could achieve 10^{22} m^{-3}
- The variation of **plasma density** ranges from $10^{18} \text{ m}^{-3} \sim 10^{22} \text{ m}^{-3}$



The relationship between the contact temperature and metal vapor density



02. Simulations of post-arc sheath

■ The influence of metal vapor-introduction of PIC-MCC model

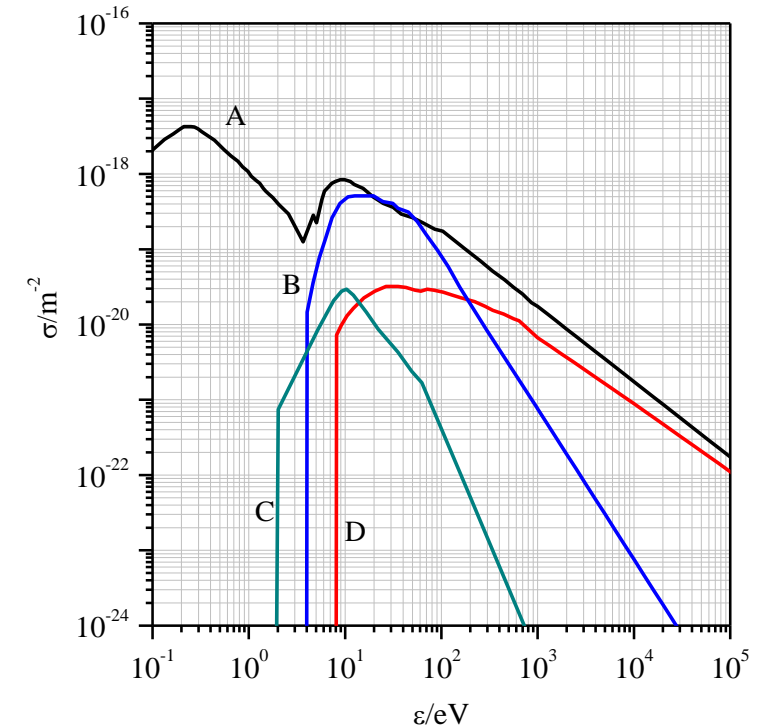
■ Electron and metal vapor

- Elastic collision
- Ionization collisions
- Excitation collision

■ Ion and metal vapor

- Charge exchange collision
- Momentum exchange collision

The collisions between the charged particles and metal vapor are dealt with Monte Carlo collision method (MCC)



collision cross section between electrons and copper atoms.
A: elastic collisions, B: excitation for the $3d^{10}4p^2P_{1/2}$ and $3d^{10}4p^2P_{3/2}$, C: excitation for the $3d^94s^2^2D_{5/2}$ D: ionization.

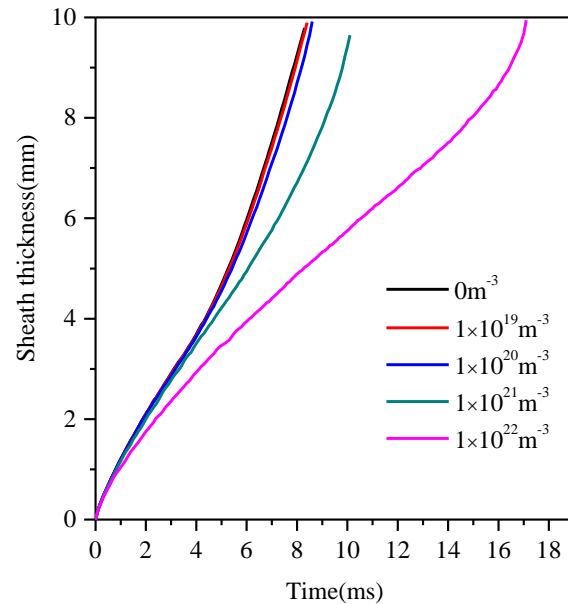


02. Simulations of post-arc sheath

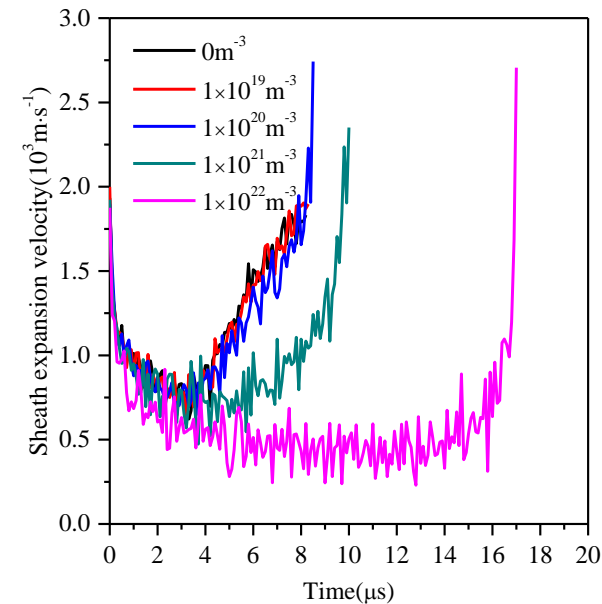
■ The influence of metal vapor

■ The post-arc sheath without initial plasma drift velocity

- The metal vapor shows small influence on the post-arc sheath when the metal vapor density is smaller than 10^{20}m^{-3}
- The metal vapor slows down the post-arc sheath expansion process when the metal vapor density is larger than 10^{21}m^{-3}



The variation of sheath thickness



The variation of sheath expansion velocity

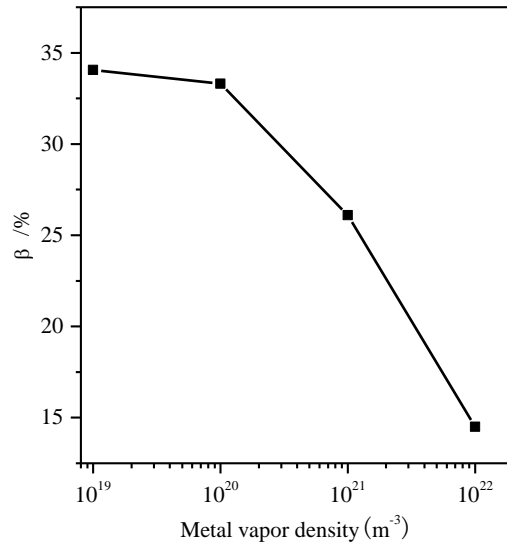


02. Simulations of post-arc sheath

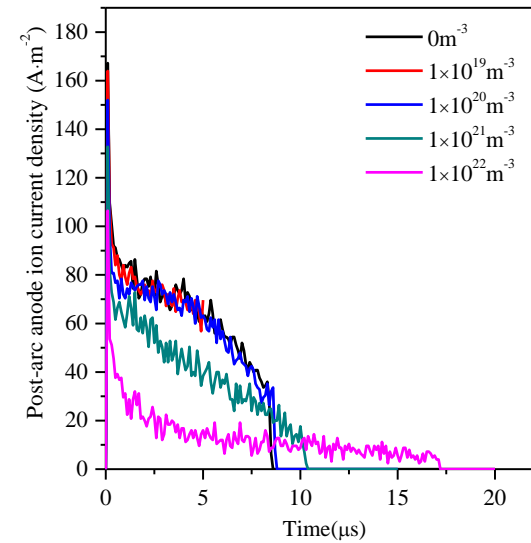
■ The influence of metal vapor

■ The proportion of ions entering post-arc anode and total electrons β

- The metal vapor shows small influence on the β and the post-arc anode ionic current density when it is smaller than 10^{20}m^{-3}
- the β and the post-arc anode ionic current density decreases obviously when the metal vapor density is larger than 10^{21}m^{-3}



The variation of β



The variation of post-arc anode ionic current density

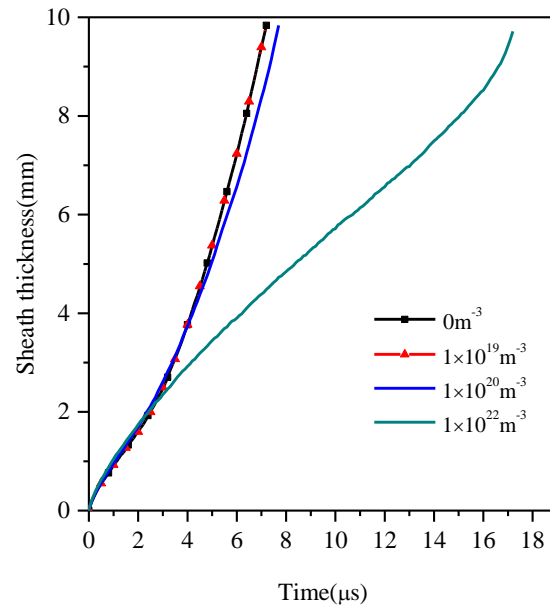


02. Simulations of post-arc sheath

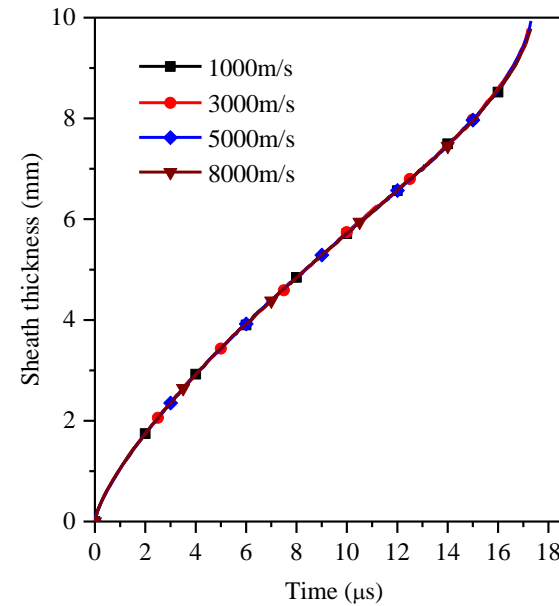
■ The influence of metal vapor

■ The post-arc sheath with initial plasma drift velocity

- The metal vapor show small influence on the post-arc sheath when it is small than 10^{20}m^{-3}
- The metal vapor shows dominant influence on the post-sheath when it is 10^{22}m^{-3} . Meanwhile the v_{drift} shows no influence on the post-arc sheath



The variation of sheath thickness with $v_{\text{drift}}=1000\text{m/s}$



The variation of sheath thickness with $1\times 10^{22}\text{m}^{-3}$

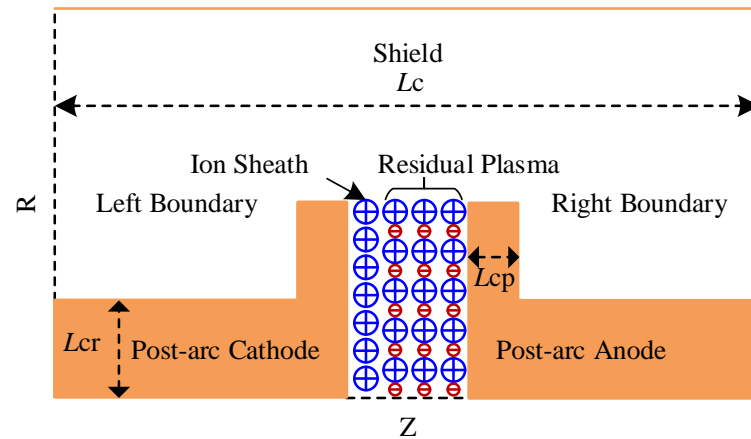


02. Simulations of post-arc sheath

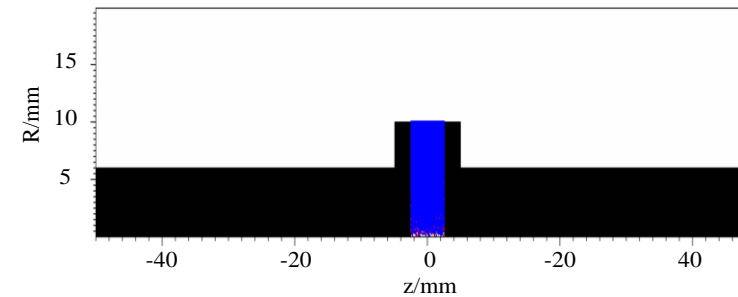
■ The plasma radial motions

■ 2-D PIC model

- Shield, right boundary and post-arc anode are zero potential
- The plasma is distributed uniformly in the gap
- The equipotential lines in the left boundary is supposed to be parallel to the axis of contacts



Schematic diagram of two-dimensional PIC model



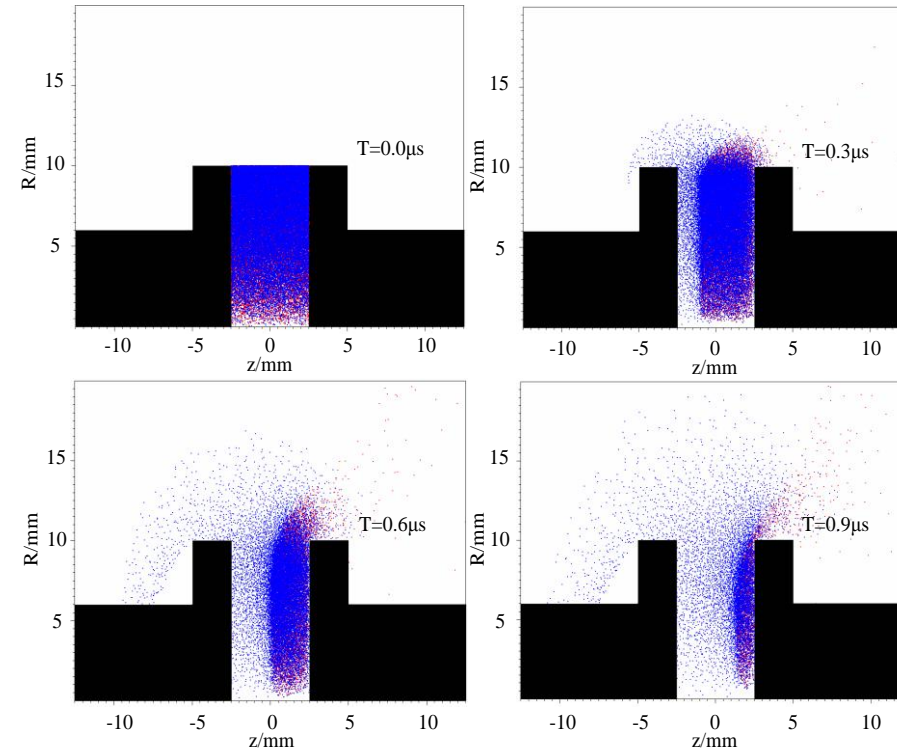
PIC model with $L_c=100$ mm
(ions are in blue and electrons are in red)



02. Simulations of post-arc sheath

- The plasma radial motions
 - The dissipation of residual plasma

- The residual plasma diffuses out the contact gap
- The shape of sheath edge develops from flat to curve
- The ions would fly to 5~10 mm away with the post-arc cathode surface and then be absorbed



The variation of residual plasma with $L_c = 25$ mm

Contents



Background



Simulations of post-arc sheath



Simulations of post-arc current



Experimental studies of post-arc current



Summary

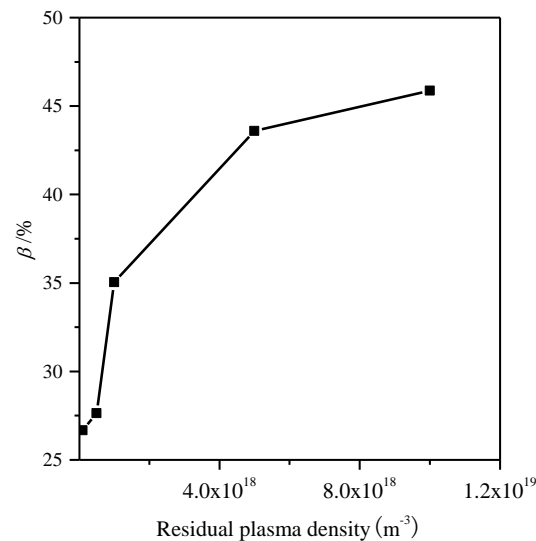


03. Simulations of post-arc current

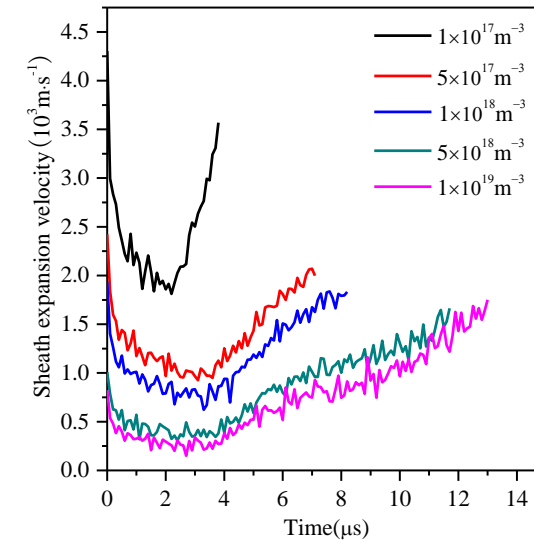
■ Influences on the proportion of ions and total electrons entering post-arc anode (β) are studied as part of ions are absorbed by the post-arc anode

■ Influence of residual plasma density

- The post-arc sheath expansion process becomes slower with the increase of residual plasma density
- The β also increases with the residual plasma density
- The β approaches saturation when the residual plasma density is larger than $5 \times 10^{18} \text{ m}^{-3}$



The β with different residual plasma densities



The sheath expansion velocity with different residual plasma densities

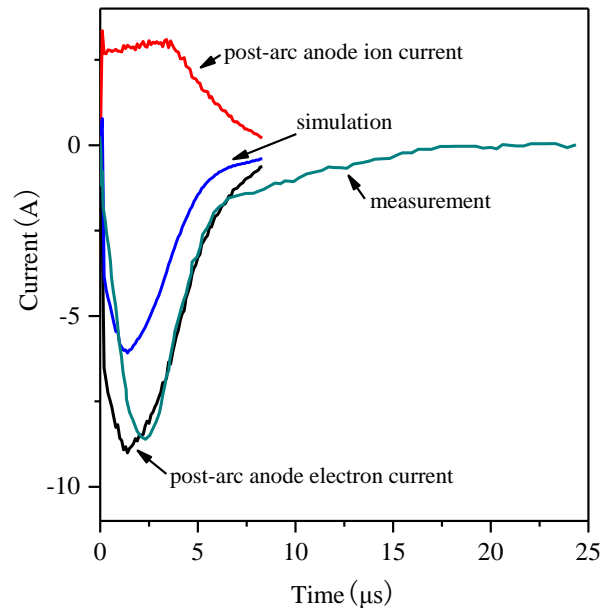


03. Simulations of post-arc current

■ Influences on the post-arc current density

➤ Comparison with measurement and simulation

- The variation of simulation results is smaller than measurement
- The peak value and duration time of post-arc current obtained from simulation is smaller than measurement.



Comparison with simulations and measurements

◆ The ions entering the post-arc anode are neglected when estimating the residual plasma. As a result, the estimated residual plasma density is small

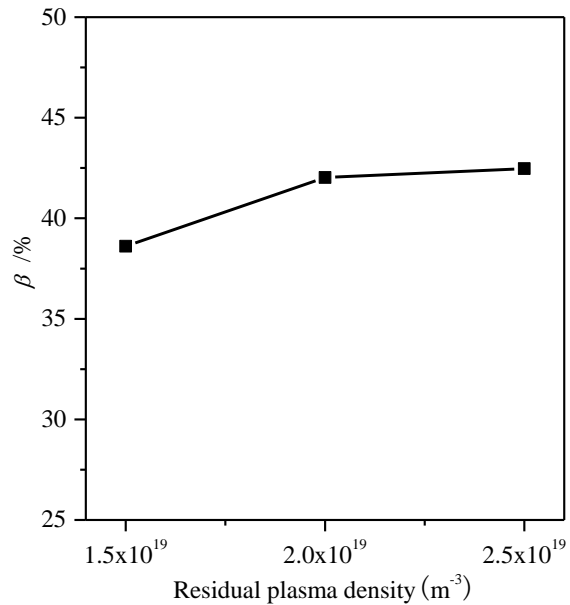


03. Simulations of post-arc current

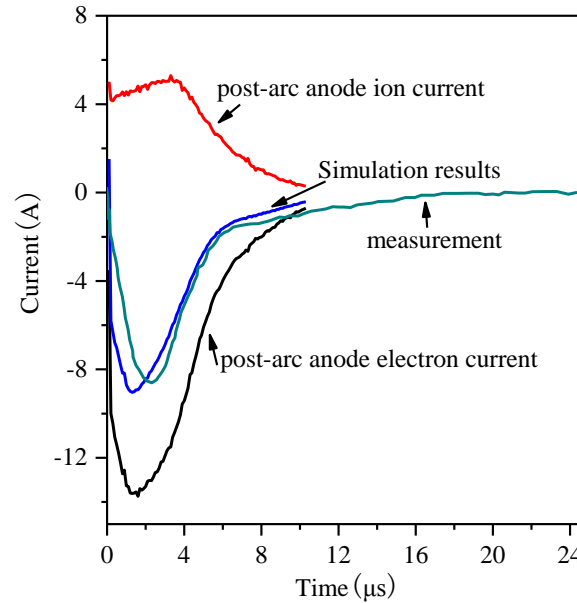
Influences on the post-arc current density

Comparison with simulations and measurements

- Adjusting the residual plasma density according to β $Q/(1-\beta)$
- The simulated post-arc current is more closer to measurement after adjustment.








The β with different residual plasma density



Comparison with measurement and simulations

Contents

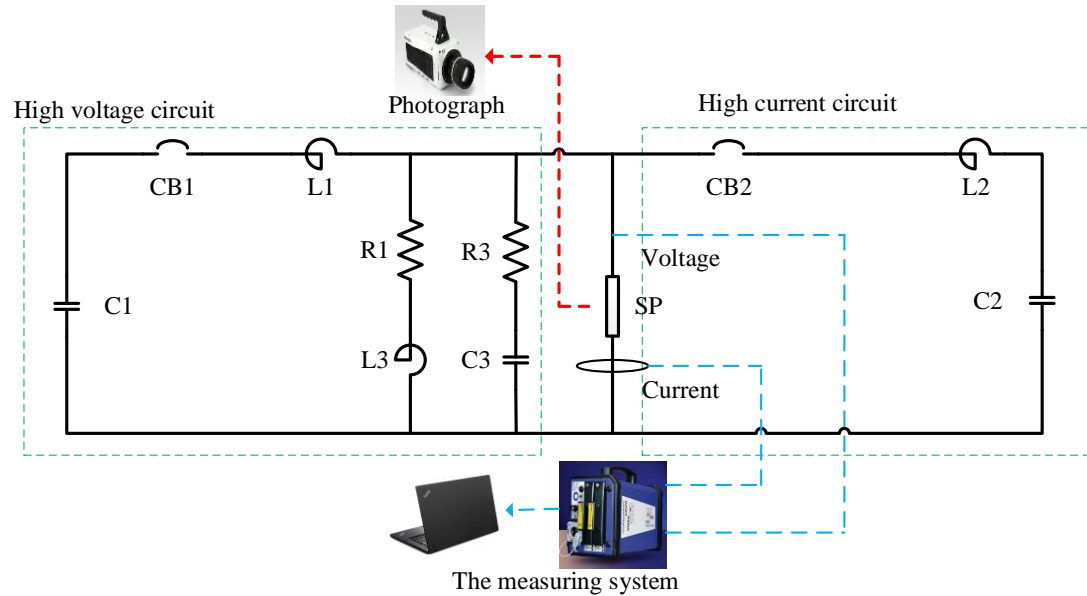


-  **Background**
-  **Simulations of post-arc sheath**
-  **Simulations of post-arc current**
-  **Experimental studies of post-arc current**
-  **Summary**



04. Experimental studies of post-arc current

■ Experimental setup



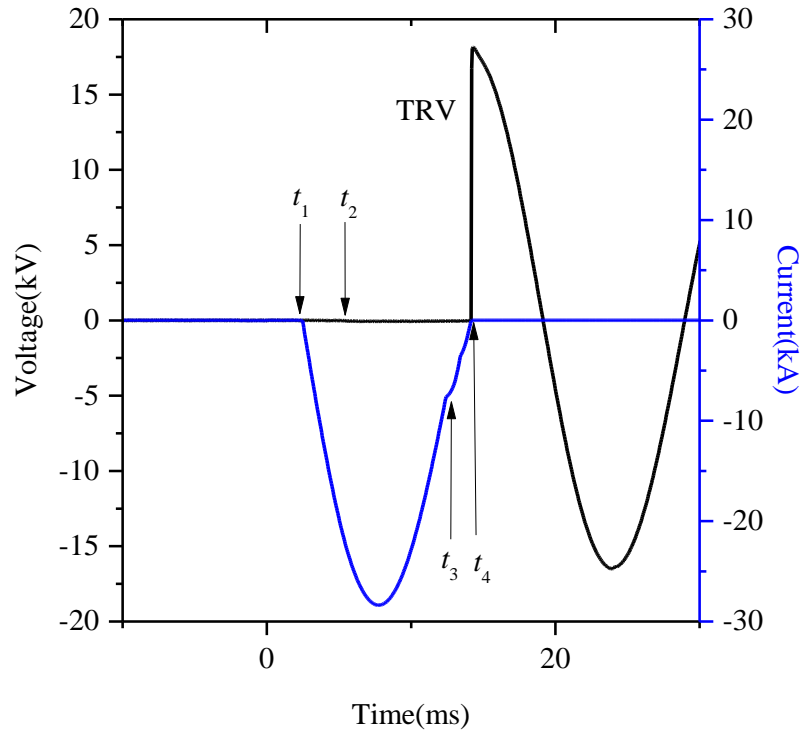
Synthetic circuit

- The post-arc current is measured by a high-resolution current-zero diagnostic system.
- The vacuum arc is recorded by a high speed camera (exposure: $2 \mu\text{s}$, frame rate : 19000 fps)

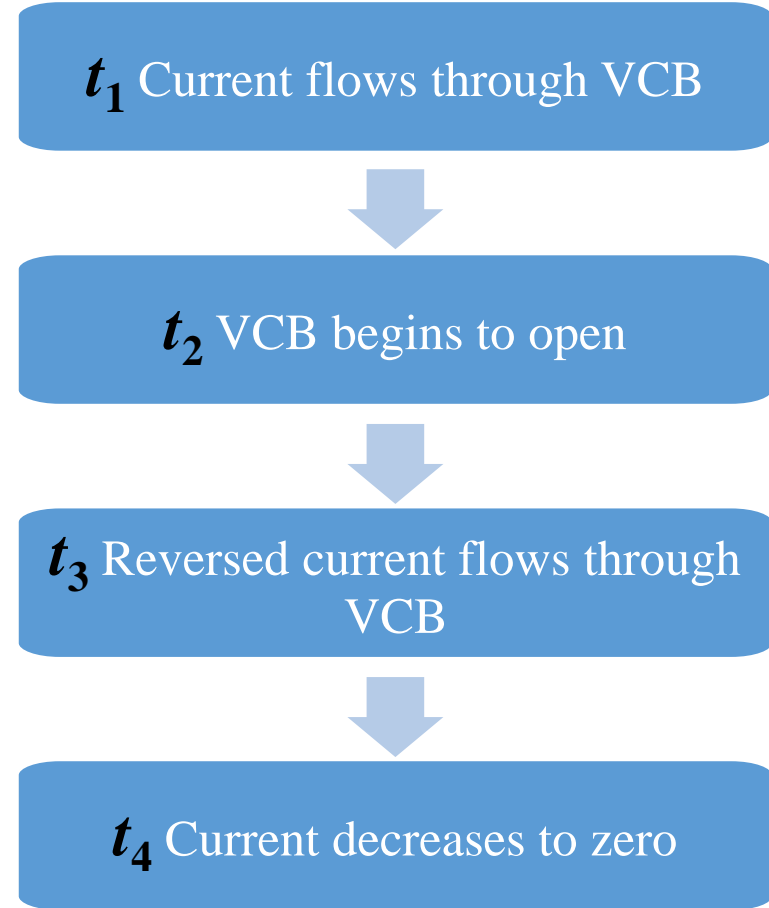


04. Experimental studies of post-arc current

■ Experimental setup



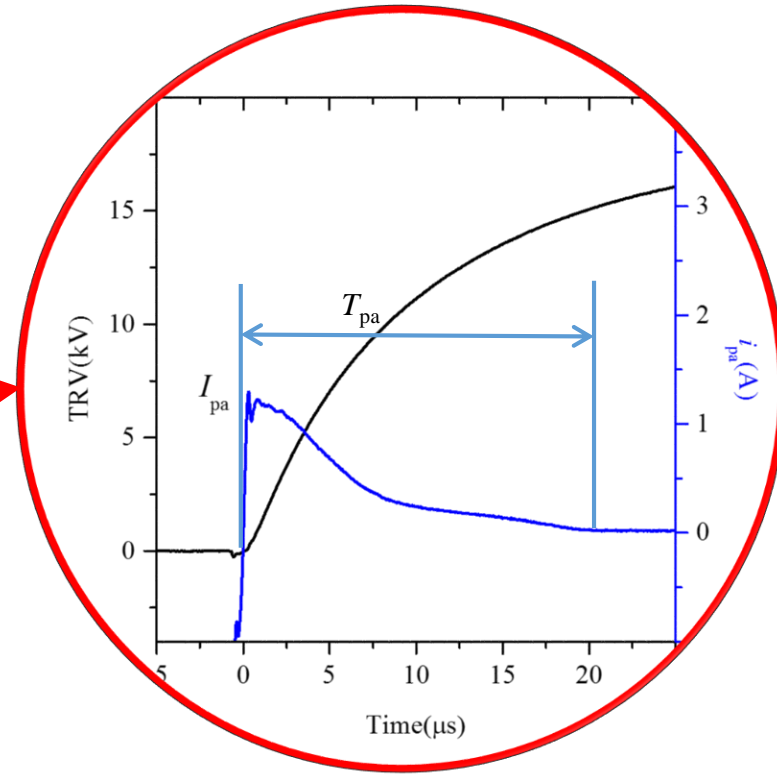
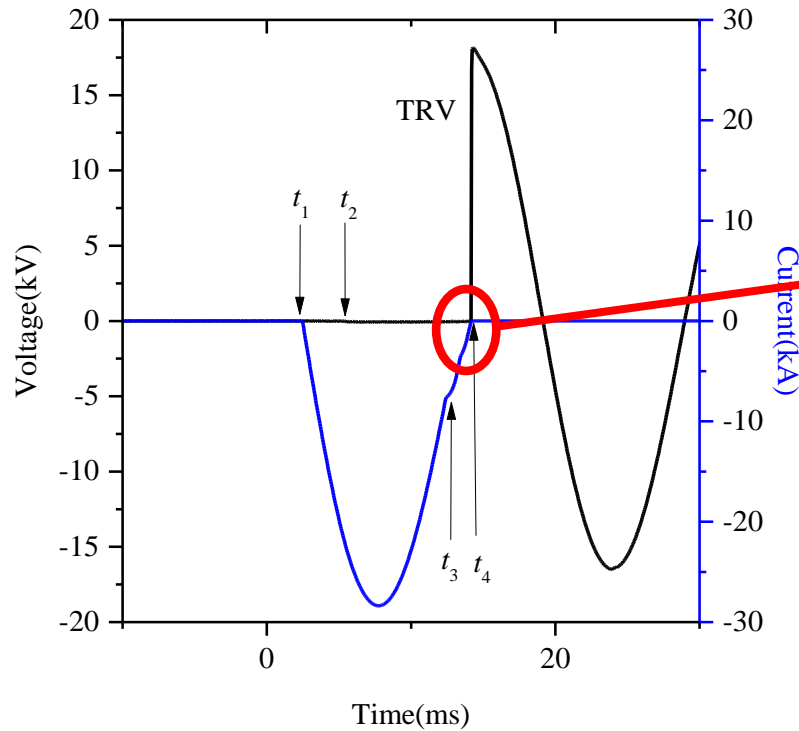
A typical waveform of the current interruption process in a vacuum circuit breaker.





04. Experimental studies of post-arc current

■ Typical post-arc current



A typical waveform of the current interruption process in a vacuum circuit breaker.

$$Q = \int_{T_{pa}} i_{pa}(t) dt$$



04. Experimental studies of post-arc current



■ Contact parameters

TABLE. 1 Types of different contacts

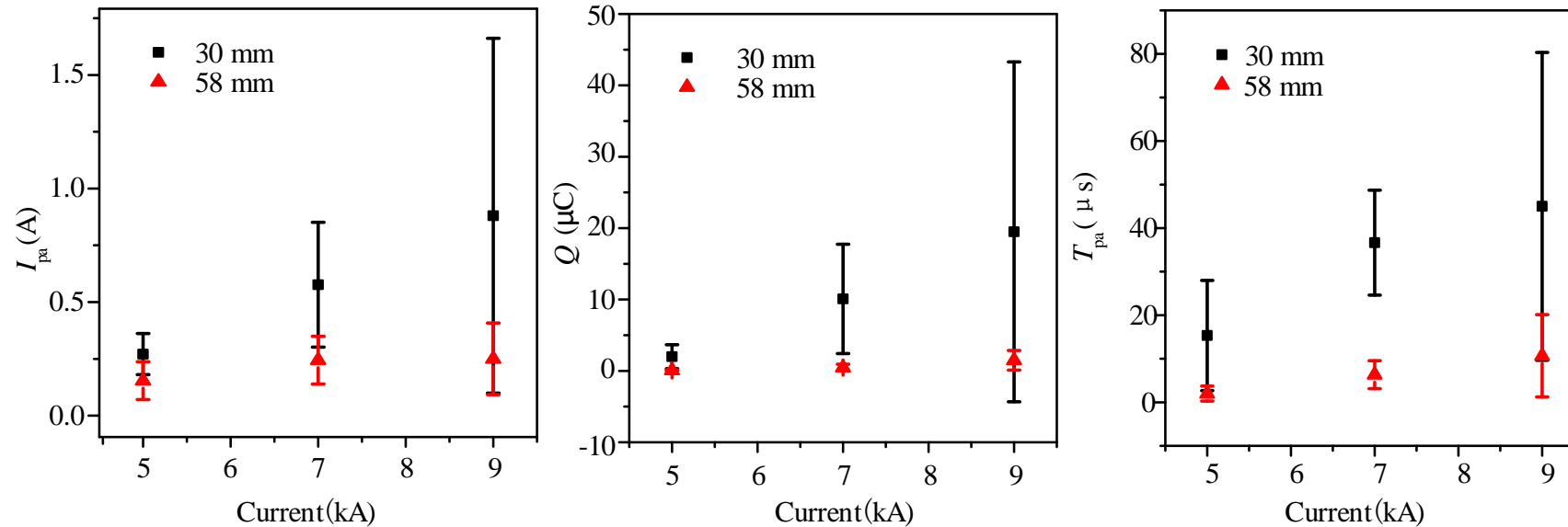
Abbreviations	Diameter(mm)	Materials	Structure
30mm-Cu-butt	30	Cu	Butt
58mm-Cu-butt	58	Cu	Butt
58mm-Cu-TMF	58	Cu	TMF
58mm-CuCr50-AMF	58	CuCr50	AMF
58mm-CuCr50-TMF	58	CuCr50	TMF

Five types of contacts are adopted to study the influence of **diameter**, **material** and **structure** on the post-arc current.



04. Experimental studies of post-arc current

■ The influence of diameter



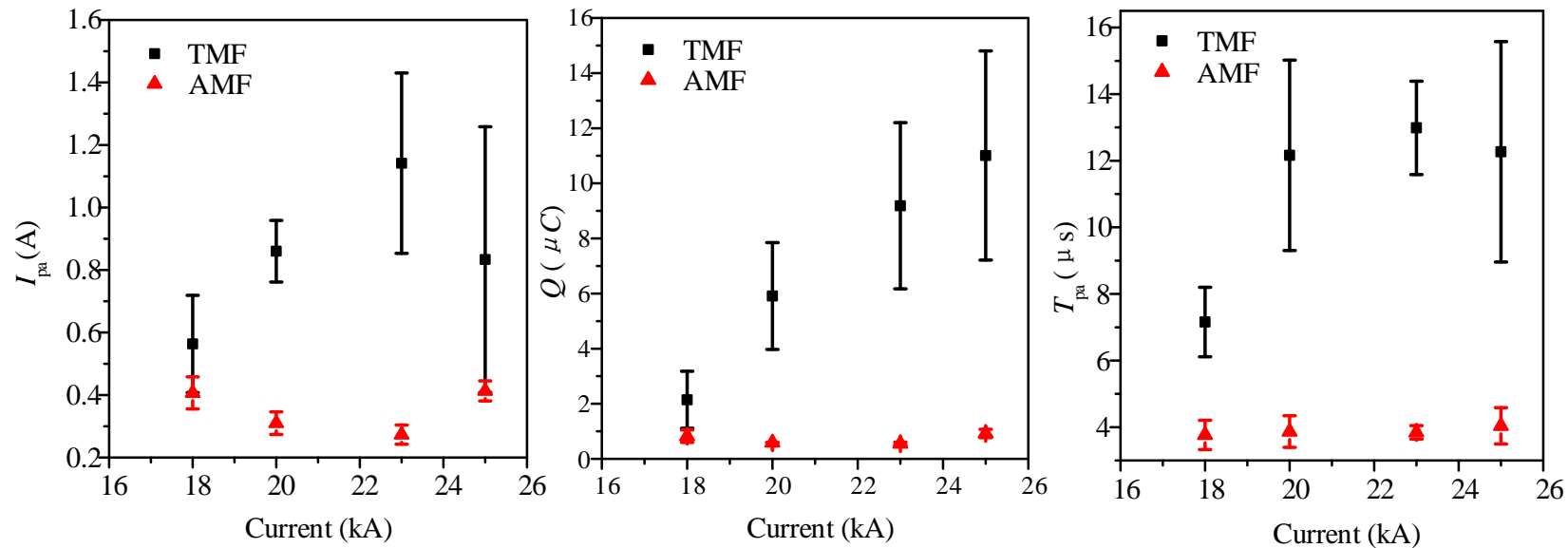
A comparison of I_{pa} , Q and T_{pa} with different diameters

➤ The I_{pa} , Q and T_{pa} of 30mm-Cu-butt contact is higher than that of 58mm-Cu-butt contact with the same current.



04. Experimental studies of post-arc current

■ The influence of structure



A comparison of I_{pa} , Q and T_{pa} with different structure

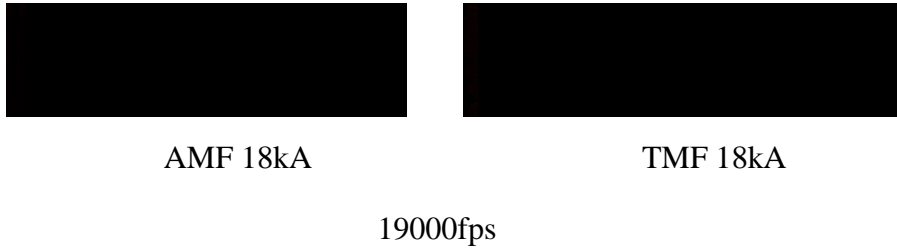
- The I_{pa} , Q and T_{pa} of 58mm-CuCr50-TMF contact is higher than that of 58mm-CuCr50-AMF contact with the same current.



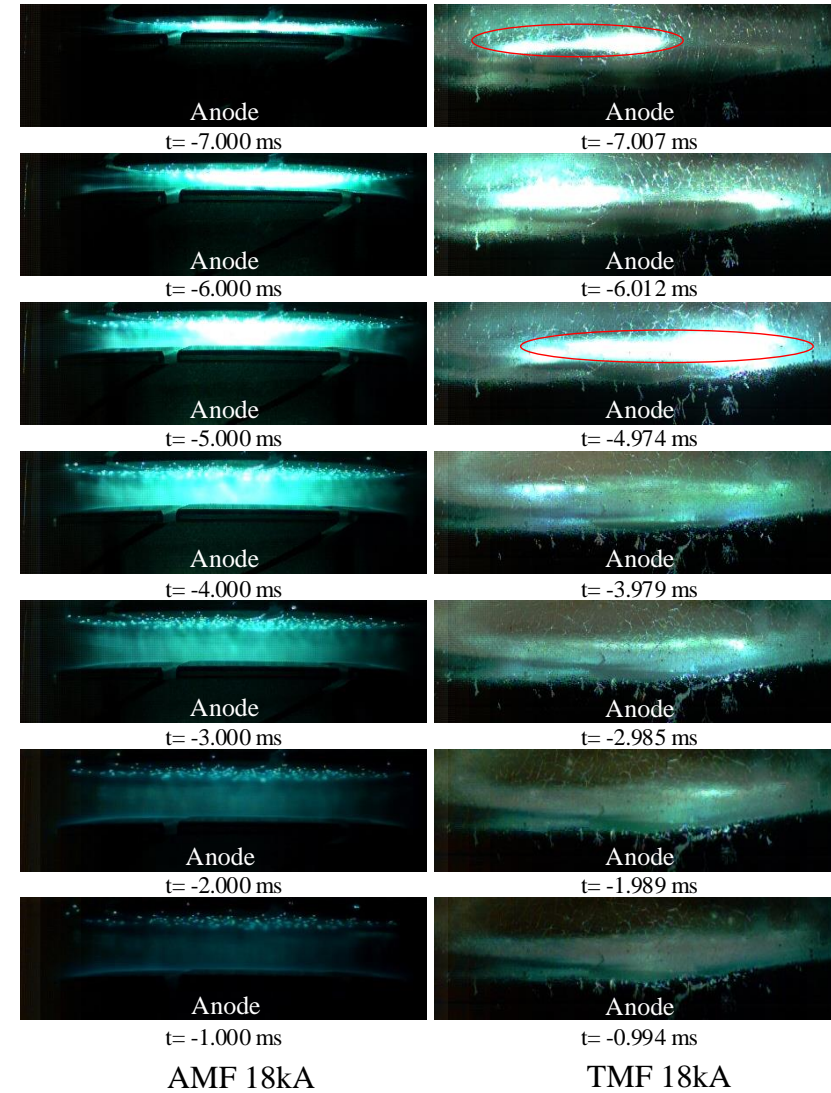
04. Experimental studies of post-arc current



■ The influence of structure



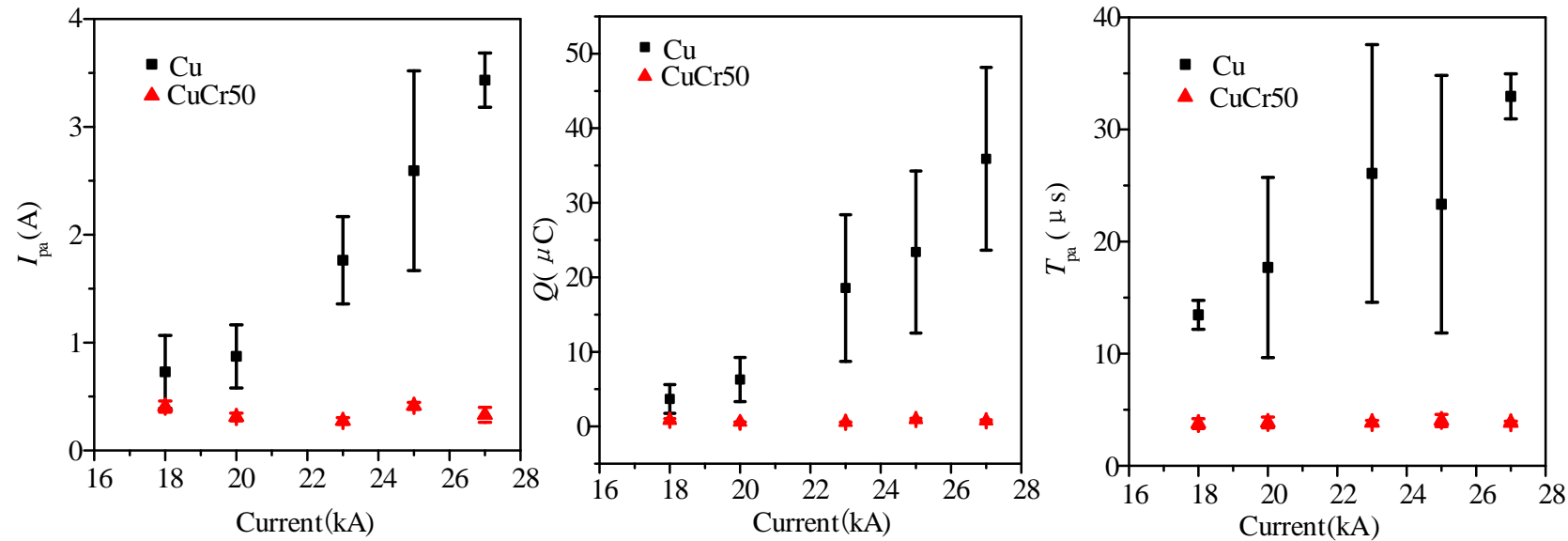
- The vacuum arc of TMF contact burns more intensely than that of AMF contact.
- The vacuum arc of TMF contact are more unstable.
- The more intense vacuum arc of TMF contact results in a higher post-arc current.





04. Experimental studies of post-arc current

■ The influence of materials



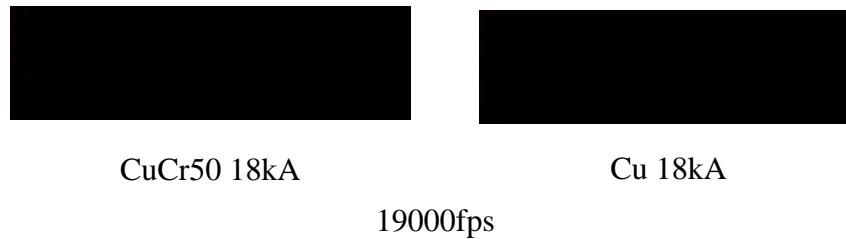
A comparison of I_{pa} , Q and T_{pa} with different materials

➤ The I_{pa} , Q and T_{pa} of the Cu contact is higher than that of CuCr50 contact with the same current.

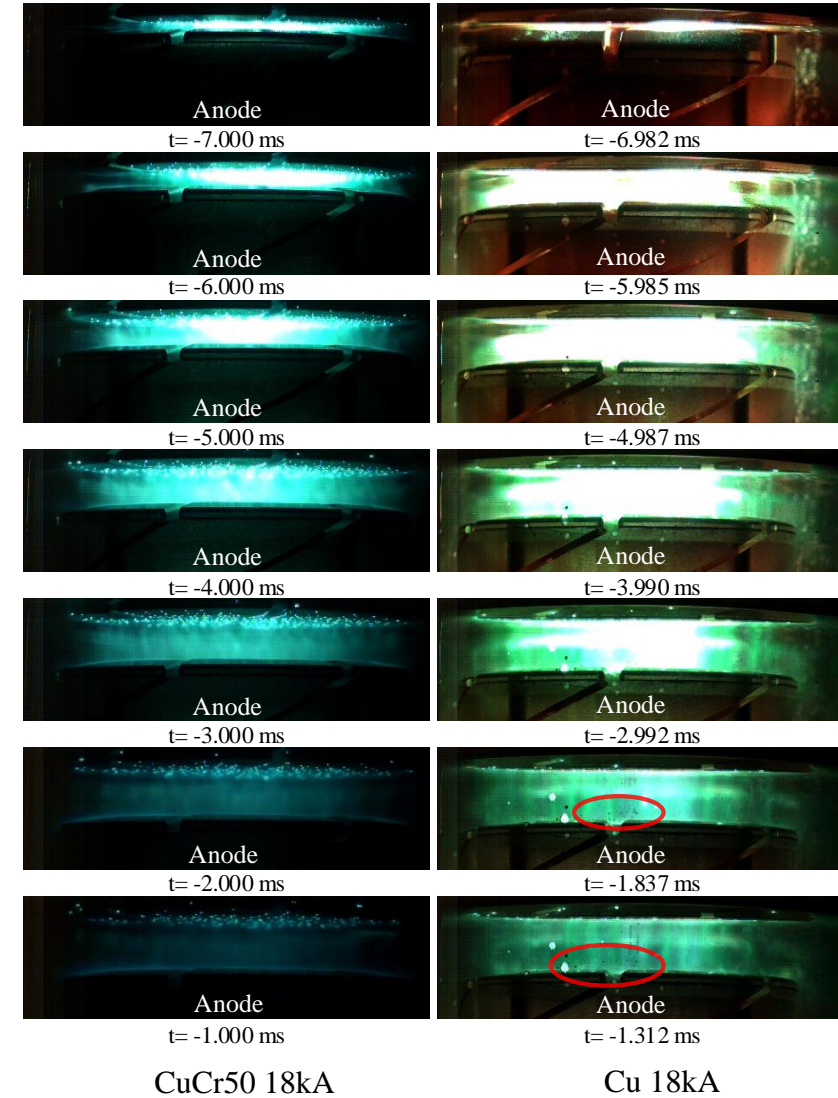


04. Experimental studies of post-arc current

■ The influence of materials



- Droplets occurs between the Cu contact.
- The vacuum arc of Cu contact burns more intensely than that of CuCr50 contact.
- The more intense vacuum arc of Cu contact also results in higher post-arc current.





04. Summary

- The plasma temperature, initial plasma drift velocity and plasma radial motion have effect on the post-arc sheath expansion processes and post-arc current. The post-arc sheath expands fast with higher plasma temperature or initial plasma drift velocity.
- The ions absorbed by the post-arc anode has a significant affect on post arc current. The simulations indicate that the residual plasma density, the metal vapor density show relatively obvious influence on the ions absorbed by the post-arc anode.
- The experimental results indicates that the vacuum arc modes can influence the post-arc current. The post-arc current value and duration time increase when the vacuum arcs more intense.



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Thank you for your attention !

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